

FORM PTO-1449 (Modified)			Attorney Docket No.: 016301-035000US		Application No.: 09/759,854	
LIST OF PATENTS AND PUBLICATIONS FOR APPLICANT'S INFORMATION DISCLOSURE STATEMENT (Use several sheets if necessary)			Applicant: Christopher Ngai, et al.			
			Filing Date: January 12, 2001		Group: 2812 2823	
Reference Designation			U.S. PATENT DOCUMENTS			Page 1
Examiner Initial	Document No.	Date	Name	Class	Sub-class	Filing Date (If Appropriate)
FOREIGN PATENT DOCUMENTS						
	Document No.	Date	Country	Class	Sub-class	Translation (Yes/No)
OTHER ART (Including Author, Title, Date, Pertinent Pages, Etc.)						
<u>QVB</u> A	Baliga, John, "New Materials Enhance Memory Performance," <i>Semiconductor International</i> (November 1999) Pages: 79-90.					
<u>QVB</u> B	DeJule, Ruth, "SOI Comes of Age," <i>Semiconductor International</i> (November 1999) Pages: 67-74.					
<u>QVB</u> C	Peters, Laura, "Solving the Integration Challenges of Low-k Dielectrics," <i>Semiconductor International</i> (November 1999) Pages: 56-64.					
<u>QVB</u> D	Peters, Laura, "Pursuing the Perfect Low-k Dielectric," <i>Semiconductor International</i> (September 1998) Pages: 64-74.					
<u>QVB</u> E	Singer, Peter, "Dual-Damascene Challenges Dielectric Etch," <i>Semiconductor International</i> (August 1999) Pages: 68-72.					
EXAMINER <u>William M. E. Smith</u>			DATE CONSIDERED <u>2 OCT 2003</u>			

EXAMINER: Initial if reference considered, whether or not citation is in conformance with MPEP 609; Draw line through citation if not in conformance and not considered. Include copy of this form with next communication to applicant.